

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re: Hatakeyama et al.
Serial No. To Be Assigned
Filed: Concurrently Herewith
For: *Resist Composition*

Date: July 9, 2003

Mail Stop PATENT APPLICATION
Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

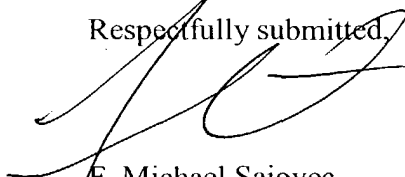
INFORMATION DISCLOSURE STATEMENT

Sir:

Attached is a list of documents on form PTO-1449. All items listed on the PTO-1449 were cited in parent application Serial No. 09/697,120, filed October 27, 2000. Since the benefit of this application is claimed under 35 U.S.C. §120, no copies need to be furnished in accordance with 37 C.F.R. §1.98(d); however, copies will be furnished on request. It is requested that these documents be considered by the Examiner and officially made of record in accordance with the provisions of 37 C.F.R. §1.97 and Section 609 of the MPEP.

No fee is believed due. However, the Commissioner is hereby authorized to charge any deficiency or credit any overpayment to our Deposit Account No. 50-0220.

Respectfully submitted,


F. Michael Sajovec
Registration No. 31,793



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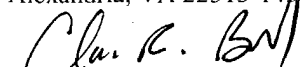
PATENT TRADEMARK OFFICE

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Clara R. Beard

FORM PTO-1449 U.S. Department of Commerce Patent and Trademark Office LIST OF DOCUMENTS CITED BY APPLICANT (Use several sheets if necessary)				Attorney Docket Number 5576-120DV		Serial No. To Be Assigned	
				Applicants: Hatakeyama et al.			
				Filing Date Concurrently Herewith		Group To Be Assigned	
U. S. PATENT DOCUMENTS							
Examiner Initial		Document Number	Date	Name	Class	Subclass	Filing Date if Appropriate
		4,491,628	01/01/85	Ito et al.	430	176	
		5,442,087	08/15/95	Eichhorn et al.	560	12	
		5,529,886	06/25/96	Eichhorn et al.	430	270.1	
		5,612,169	03/18/97	Eichhorn et al.	430	270.1	
		5,741,621	04/1998	Kempt et al.			
		5,968,712	10/19/99	Thackeray et al.	430	326	
		6,274,286	08/2001	Hatakeyama et al.			
FOREIGN PATENT DOCUMENTS							
		Document Number	Date	Country	Class	Subclass	Translation Yes No
		05158239 A	06/25/93	JAPAN	G03F	7/038	X (Abstract)
		05232706 A	09/10/93	JAPAN	G03F	7/039	X (Abstract)
		05249683 A	09/28/93	JAPAN	G03F	7/039	X (Abstract)
		05257282 A	10/08/93	JAPAN	G03F	7/038	X (Abstract)
		05289322 A	11/05/93	JAPAN	G03F	7/004	X (Abstract)
		05289340 A	11/05/93	JAPAN	G03F	7/039	X (Abstract)
		06194834 A	07/15/94	JAPAN	G03F	7/028	X (Abstract)
		06242605 A	09/02/94	JAPAN	G03F	7/039	X (Abstract)
		06242606 A	09/02/94	JAPAN	G03F	7/039	X (Abstract)
		06266100 A	09/22/94	JAPAN	G03F	7/004	X (Abstract)
		06266111 A	09/22/94	JAPAN	G03F	7/039	X (Abstract)
		07092678 A	04/07/95	JAPAN	G03F	7/039	X (Abstract)
		07092680 A	04/07/95	JAPAN	G03F	7/039	X (Abstract)
		07092681 A	04/07/95	JAPAN	G03F	7/039	X (Abstract)

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Initial if reference considered, whether or not citation is in conformance with MPEP 609: draw line through citation if not in

FORM PTO-1449 U.S. Department of Commerce Patent and Trademark Office LIST OF DOCUMENTS CITED BY APPLICANT (Use several sheets if necessary)					Attorney Docket Number 5576-120DV		Serial No. To Be Assigned
					Applicants: Hatakeyama et al.		
					Filing Date Concurrently Herewith		Group To Be Assigned
		07120929 A	05/12/95	JAPAN	G03F	7/039	X (Abstract)
		07128859 A	05/19/95	JAPAN	G03F	7/039	X (Abstract)
		07134419 A	05/23/95	JAPAN	G03F	7/039	X (Abstract)
OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)							
		Hinsberg et al.; "Fundamental Studies of Airborne Chemical Contamination of Chemically Amplified Resists," <i>Journal of Photopolymer Science and Technology</i> 6:4 535-546 (1993).					
		Kumada et al.; "Study on Over-Top Coating of Positive Chemical Amplification Resists for KrF Excimer Laser Lithography," <i>Journal of Photopolymer Science and Technology</i> 6:4 571-574 (1993).					
		U.S. Patent Application No. 06/873,914, Filed: June 13, 1986					

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